

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	1	("20050048375").PN.	US-PGPUB; USPAT	OR	OFF	2005/11/17 16:33
S2	1	("6274280").PN.	US-PGPUB; USPAT	OR	OFF	2005/11/18 19:32
S4	4096	((phas\$3 or shift\$3) near2 (mask or photomask or reticle) or PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:30
S5	732	S4 and ((attenuat\$3 or halftone or half tone) with (phas\$3 or shift\$3 or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:38
S6	197	S5 and ((etch\$3 or groov\$3 or recess\$3 or mesa or rais\$3 or thick\$4) with (phas\$3 or shift\$3 or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:42
S7	86	S6 and ((blank or wavelength or wave length) with (phas\$3 or shift\$3 or mask or photomask or reticle or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:05
S8	7677	430/5.ccls.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:46
S9	407	216/12.ccls.	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:47
S10	49	S6 and (S8 or S9) not S7	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:48
S11	209	S5 and (S8 or S9) not S7 not S10	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 16:53
S12	8	S11 and (reactive ion near2 etch\$3 or RIE) with ("SF.sub.6" or "CF.sub.4" or sulfur hexafluoride or carbon tetrafluoride)	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:03
S13	2	S5 and (reactive ion near2 etch\$3 or RIE) with ("SF.sub.6" or "CF.sub.4" or sulfur hexafluoride or carbon tetrafluoride) not S7 not S10 not S12	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:04

S14	(3)	S6 and ((blank or wavelength or wave length) with (phas\$3 or shift\$3 or mask or photomask or reticle or PS or PSM) or attPSM or att PSM or HPSM or H PSM) not S7 not S10 not S12 not S13	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:11
S15	(1)	S6 and ((second or third or plural or multiple) with (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or mask or photomask or reticle or PS or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab. not S7 not S10 not S12 not S13 not S14	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:13
S16	(4)	S6 and ((second or third or plural or multiple) same (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab. not S7 not S10 not S12 not S13 not S14 not S15	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:15
S17	(5)	S5 and ((second or third or plural or multiple) same (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or PSM) or attPSM or att PSM or HPSM or H PSM).ti,ab. not S7 not S10 not S12 not S13 not S14 not S15 not S16	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:17
S18	108	S5 and ((second or third or plural or multiple) same (wavelength or wave length or thick\$4) same (phas\$3 or shift\$3 or PSM) or attPSM or att PSM or HPSM or H PSM) not S7 not S10 not S12 not S13 not S14 not S15 not S16 not S17	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:19
S19	(63)	S18 and ((transmi\$6 or transpar\$6) same ((attenuat\$3 or halftone or half tone) same (phas\$3 or shift\$3 or PSM)) or attPSM or att PSM or HPSM or H PSM).ti,ab. not S7 not S10 not S12 not S13 not S14 not S15 not S16 not S17	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:24
S20	(5)	((Cheng Ming or ChengMing) near2 Lin).in. not S7 not S10 not S12 not S13 not S14 not S15 not S16 not S17 not S19	US-PGPUB; USPAT; EPO; JPO; IBM_TDB	ADJ	ON	2005/11/19 17:28